

L Number	Hits	Search Text	DB	Tim stamp
-	12	((("5455130") r ("5279911") or ("6251545") or ("20010028983") or ("20020105721") or ("20020132171")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/08 17:51
-	649	(359/580).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:00
-	1419	(430/322).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:47
-	480	(359/586).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:50
-	813	(359/589).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 10:50
-	270	((359/580).CCLS.) and (anti?reflect\$ or antireflect\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:06
-	126	((430/322).CCLS.) and (anti?reflect\$ or antireflect\$) and substrate and (layer or film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:07
-	187	((359/586).CCLS.) and (anti?reflect\$ or antireflect\$) and substrate and (layer or film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:07
-	192	((359/589).CCLS.) and (anti?reflect\$ or antireflect\$) and substrate and (layer or film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:07
-	214	((359/580).CCLS.) and (anti?reflect\$ or antireflect\$) and substrate and (layer or film)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:38

-	621	photomask and (anti?reflect\$ or antireflect\$) and substrate and (layer or film) and (uv or ultra?violet or ultraviolet)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:39
-	2	(photomask same (uv or ultra?violet or ultraviolet)) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:44
-	39	(uv or ultra?violet or ultraviolet) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum and (photomask or mask) and photolithograph\$	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 13:26
-	2	("6395433").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 12:47
-	3	(fabry with perot) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 13:32
-	117	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 13:33
-	28	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum and (mask or photomask) and (photolithograph\$ or projection)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:18
-	12	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum and birefringen\$	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:47
-	0	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and (substrate with (silica or quartz)) and magnesium and aluminum and (refract\$ with ind\$4 with inhomogen\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:48
-	0	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and substrate and magnesium and aluminum and (refract\$ with ind\$4 with inhomogen\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:48

-	0	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film)) and magnesium and aluminum and (refract\$ with ind\$4 with inhomogen\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:49
-	1	((fabry with perot) or interfer\$) and ((anti?refl ct\$ or antireflect\$) with (layer or film or coating)) and magnesium and aluminum and (refract\$ with ind\$4 with inhomogen\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:50
-	31	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film or coating)) and (refract\$ with ind\$4 with inhomogen\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 14:51
-	22	((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film or coating)) and substrate and (refract\$ with ind\$4 with inhomogen\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 15:14
-	16	((mask or photomask) with (blank or substrate or base)) same (fabry with perot)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 15:32
-	2150	((mask or photomask) with (blank or substrate or base)) same ((fabry with perot) or interfer\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 15:22
-	159	((mask or photomask) with (blank or substrate or base)) same ((fabry with perot) or interfer\$) and ((anti?reflect\$ or antireflect\$) with (layer or film or coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 15:24
-	26	((mask or photomask or reticle) with (blank or substrate or base)) same (fabry with perot)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 15:33
-	16	((mask or photomask or reticle or (photo adj mask)) with (blank or substrate or base)) same (fabry with perot)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:16
-	1722	((mask or photomask or reticle or (photo adj mask)) with (blank or substrate or base)) and ((reduc\$3 or eliminat\$3) with interfer\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:18

-	225	((mask or photomask or reticle or (photo adj mask)) with (blank or substrate or base)) and ((reduc\$3 or eliminat\$3) with interfer\$)) and ((anti?reflect\$ or antireflect\$) with (layer or film or coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:19
-	65	((mask or photomask or reticle or (photo adj mask)) with (blank or substrate or base) with ((reduc\$3 or eliminat\$3) with interfer\$))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:19
-	6	((mask or photomask or reticle or (photo adj mask)) with (blank or substrate or base) with ((reduc\$3 or eliminat\$3) with interfer\$))) and ((anti?reflect\$ or antireflect\$) with (layer or film or coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:21
-	28807	((anti?reflect\$ or antireflect\$) with (layer or film or coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:23
-	385	((anti?reflect\$ or antireflect\$) with (layer or film or coating)) same ((reduc\$3 or eliminat\$3) with interfer\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:24
-	54	((anti?reflect\$ or antireflect\$) with (layer or film or coating)) same ((reduc\$3 or eliminat\$3) with interfer\$ with (blank or substrate or base))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 16:24
-	2	("6251545").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 18:49
-	2	("20020132171").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/11 18:49